



I/V and C/V Measurements of Hamamatsu Si-Detectors

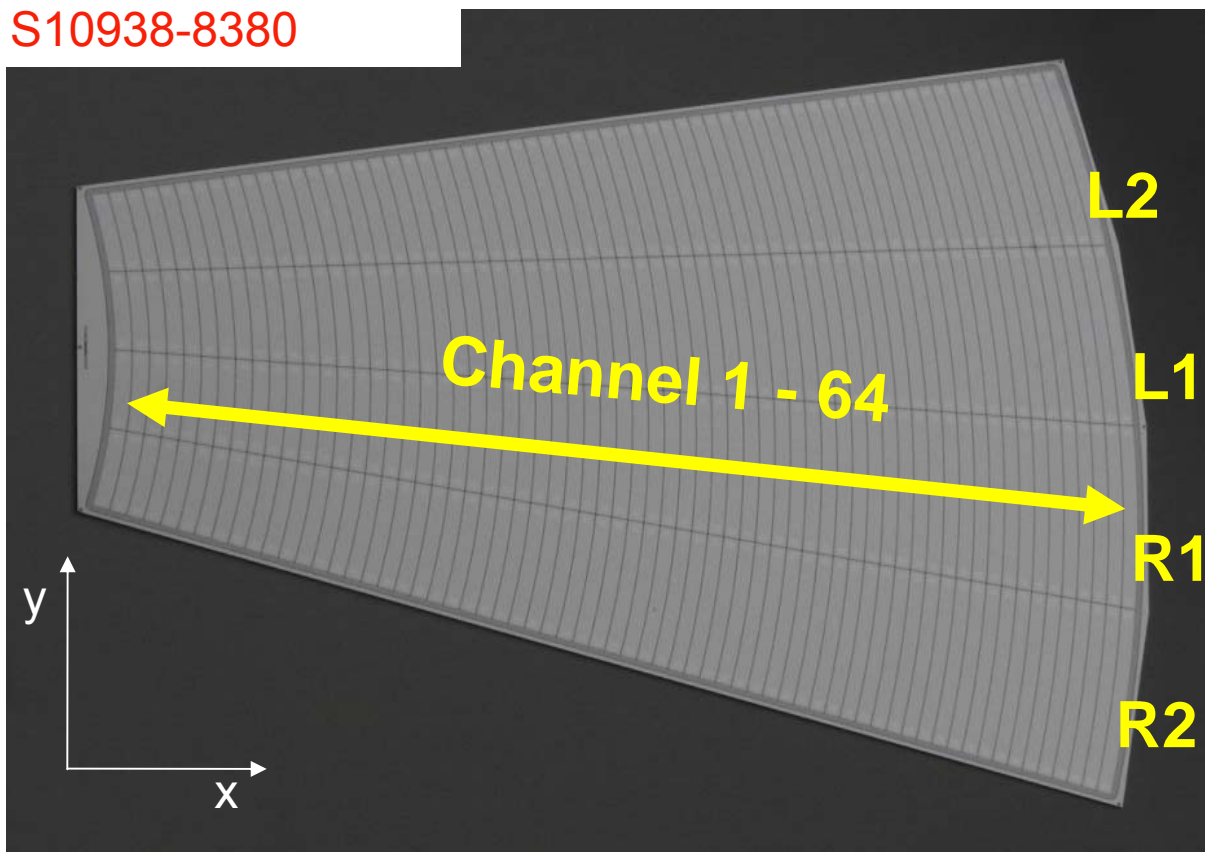
Matthias Bergholz

On behalf of DESY Zeuthen group

Detector description

Hamamatsu

S10938-8380



“Cracow-Design”

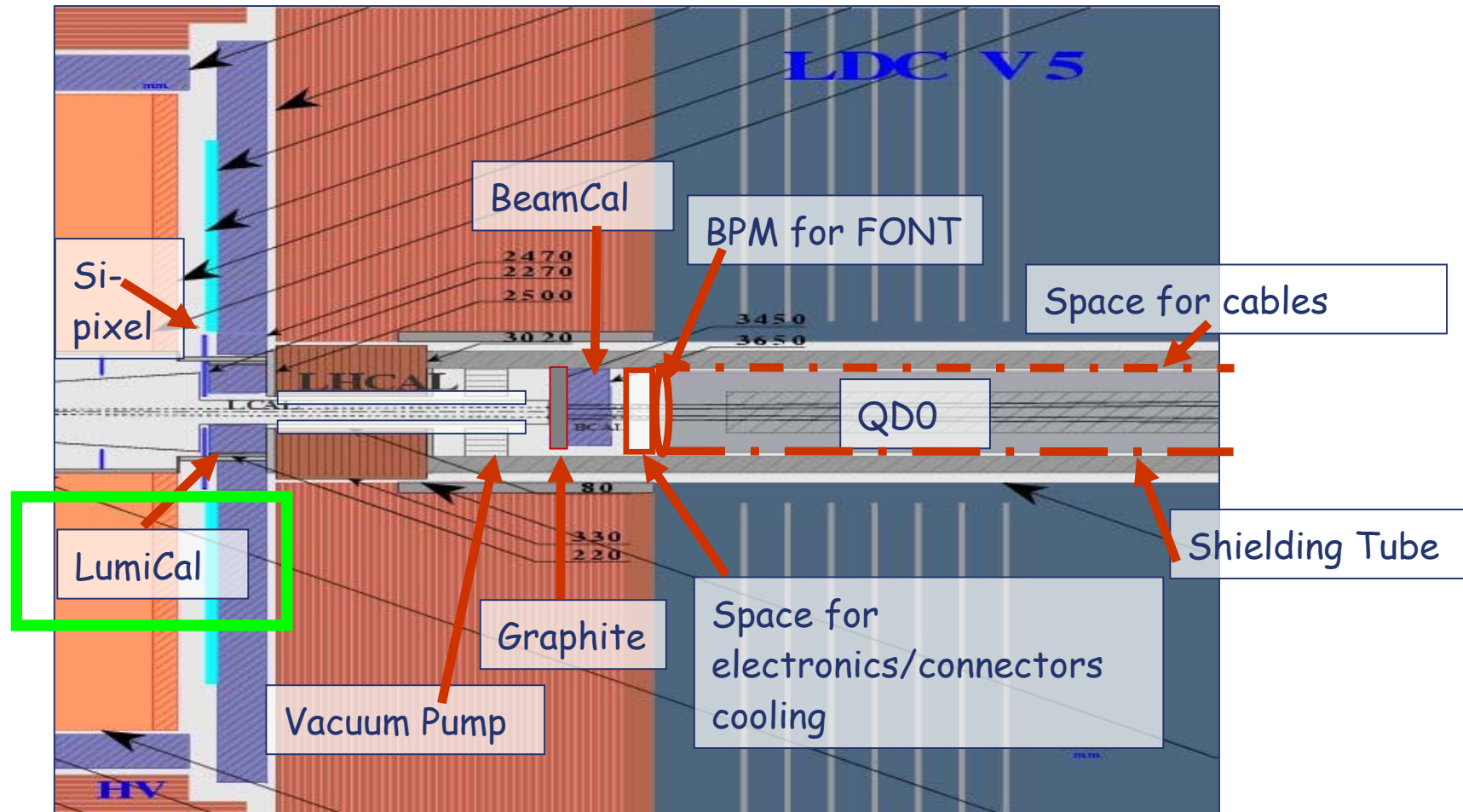
- High resistivity n-type Si
- 1,7mm p⁺ - strips with an Al-metallization
- Backplane: n⁺ implant and an Al-metallization
- 3 Guard rings

x-Size = 10,8cm

y-Size = 4...12cm

(6 Inch Wafers)

Introduction

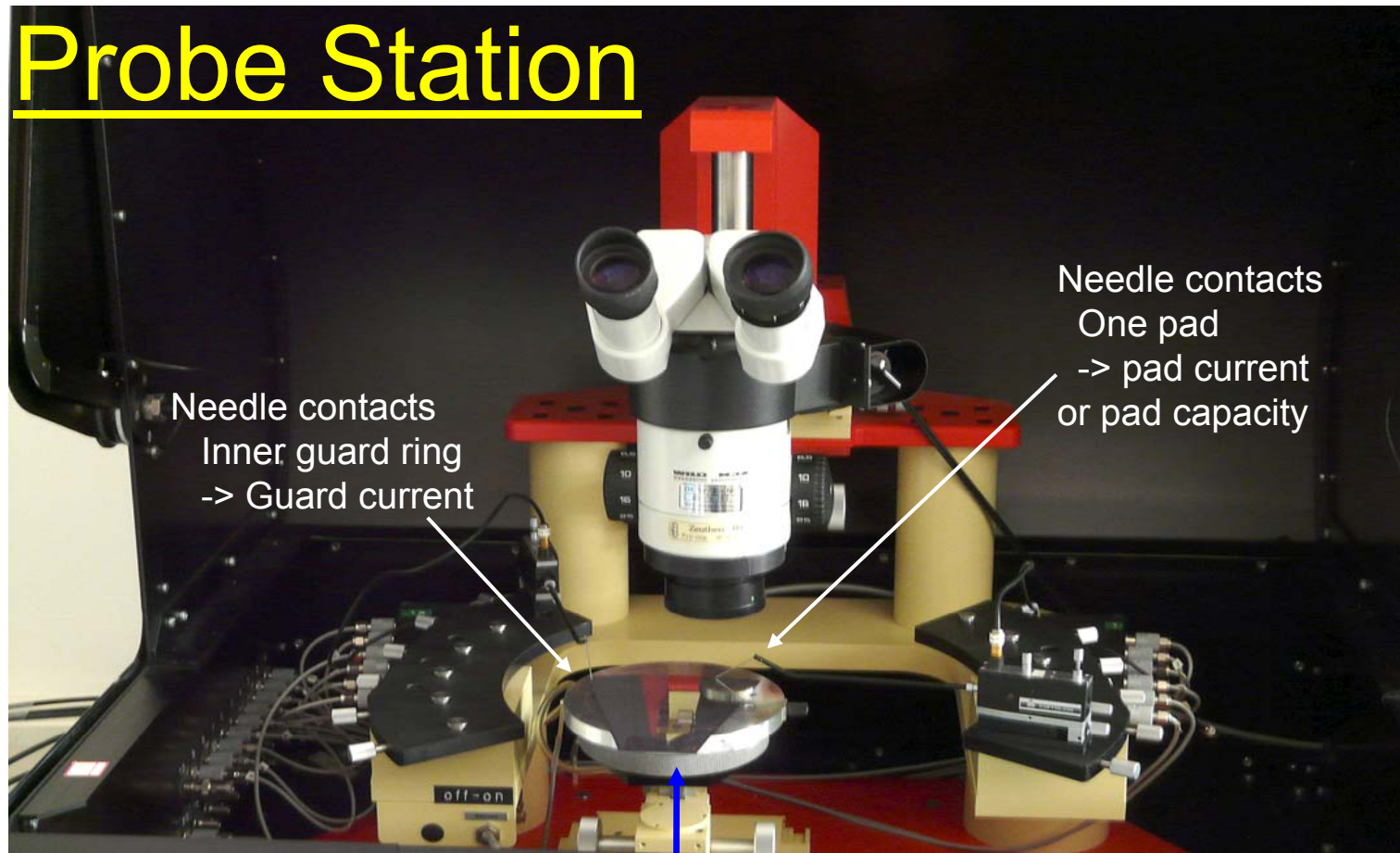




Measurement setup

Measurement setup 1

Probe Station

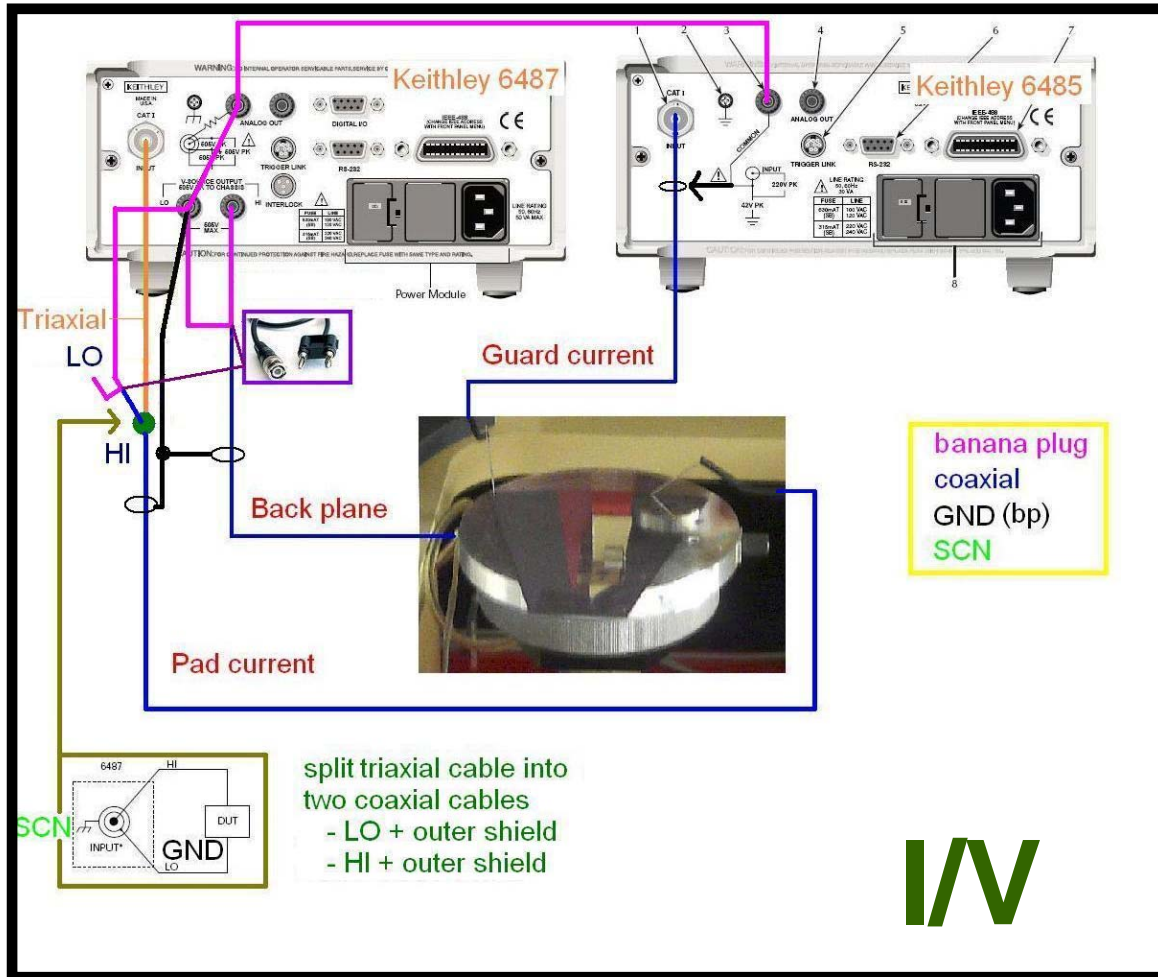


Needle contacts
Inner guard ring
-> Guard current

Needle contacts
One pad
-> pad current
or pad capacity

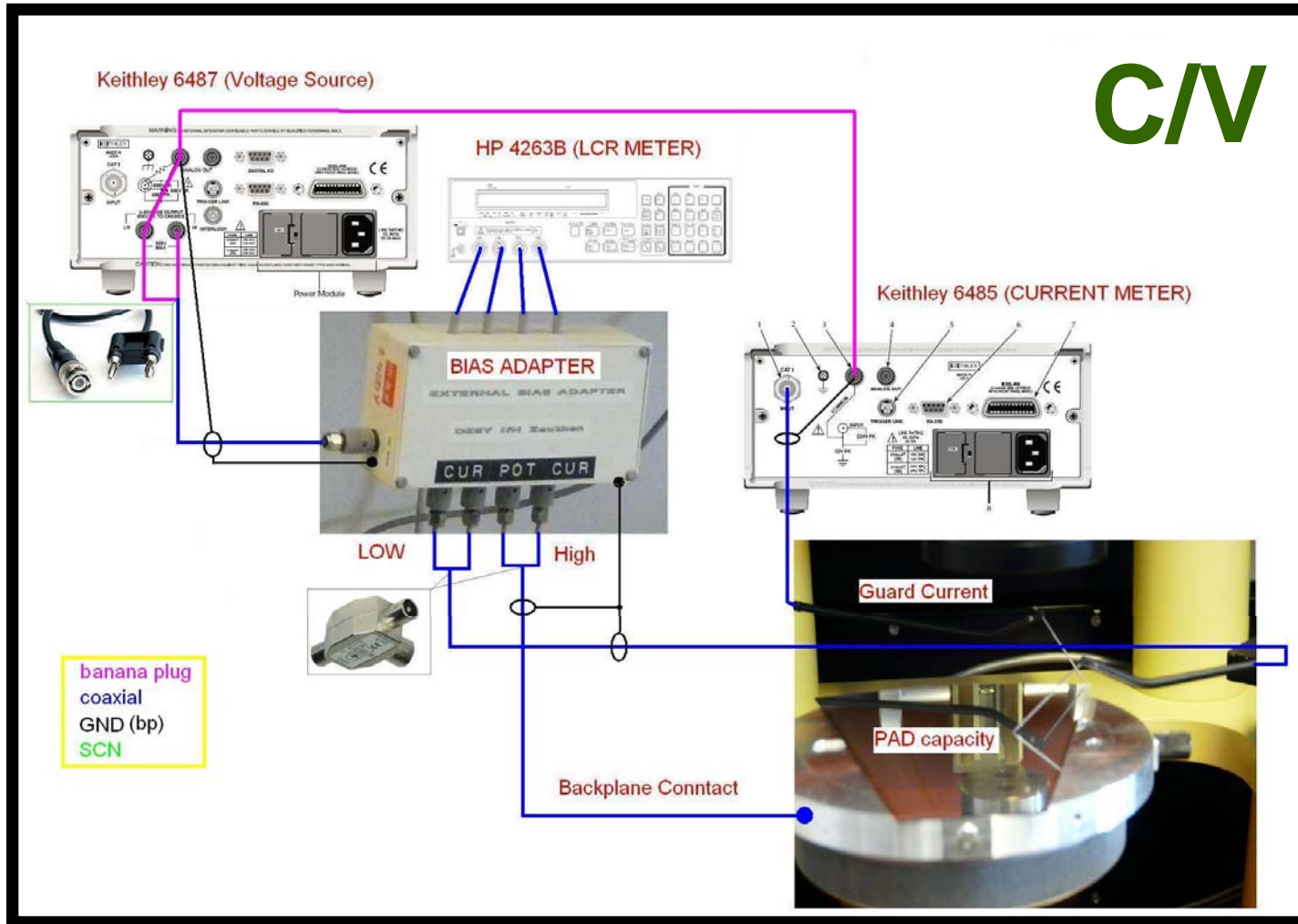
Backplane contacted via Al table ('+' of high voltage)

Measurement setup 3



Measurement setup 2

C/V



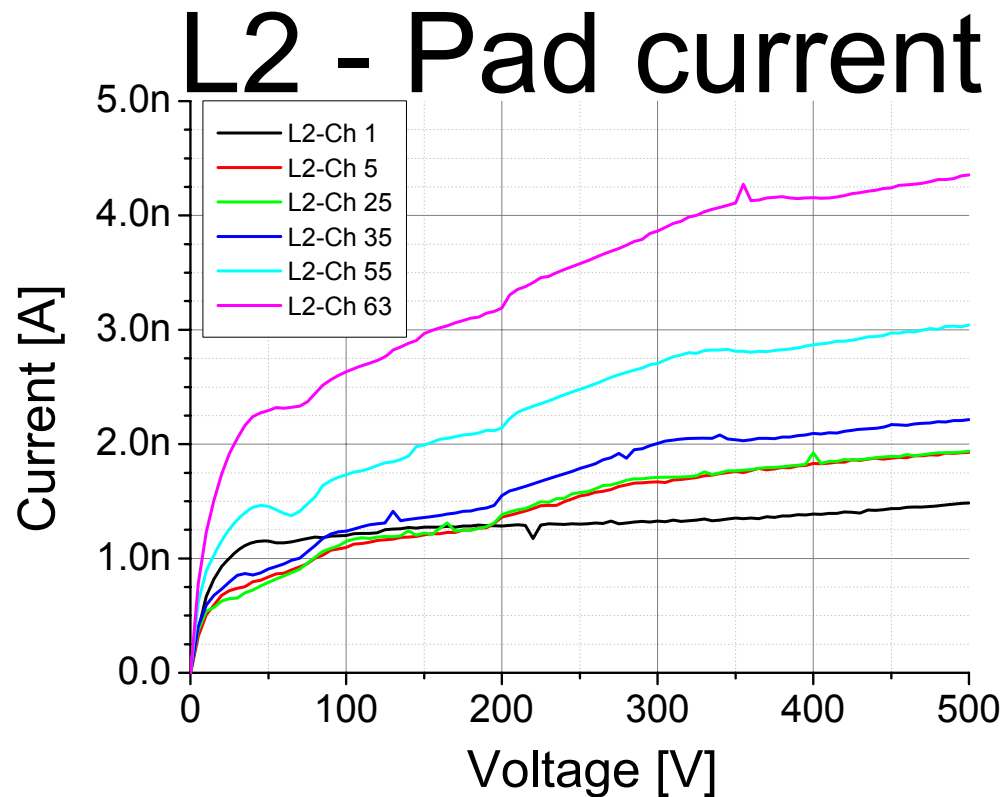
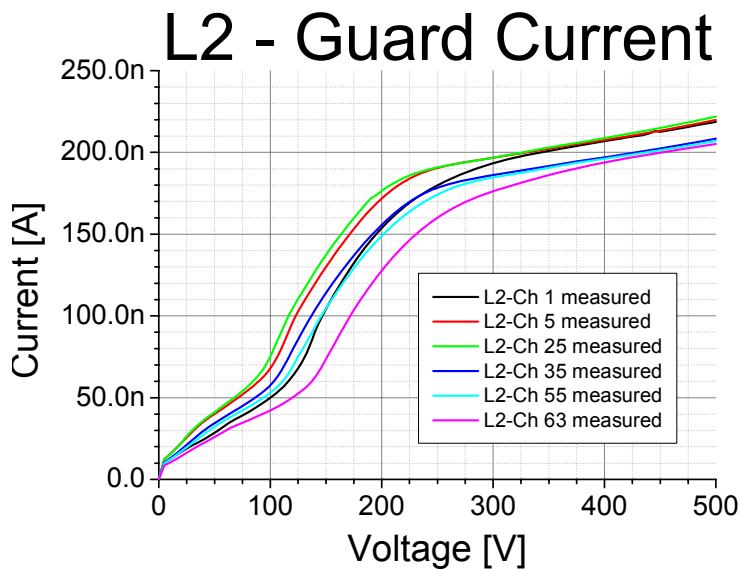


Results

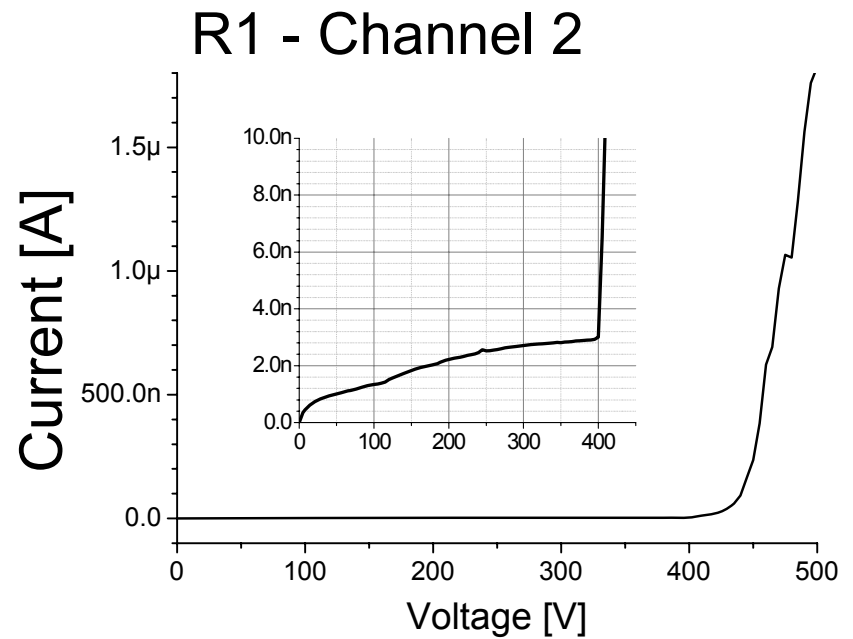
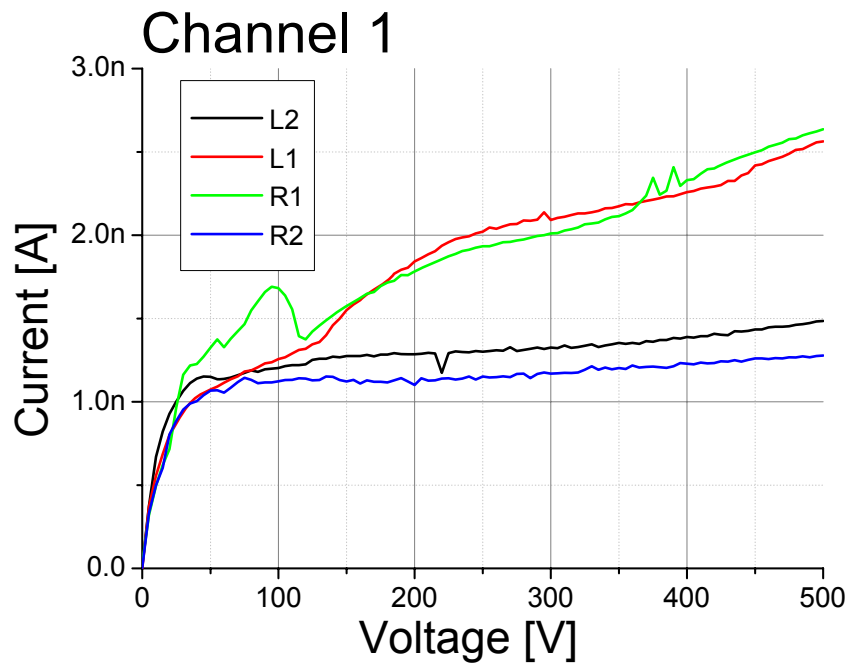
Measurement results 1



- *Inner guard ring connected to current meter*
- *Only a single pad was connected*

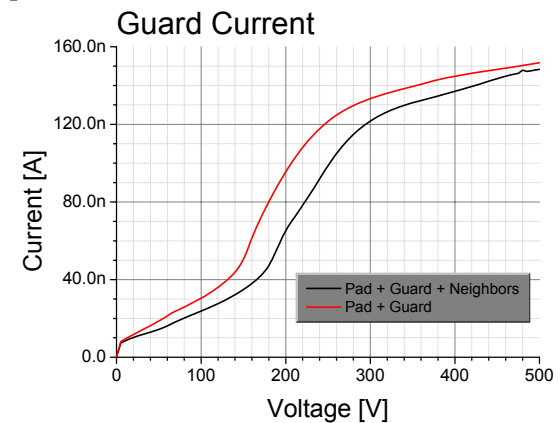
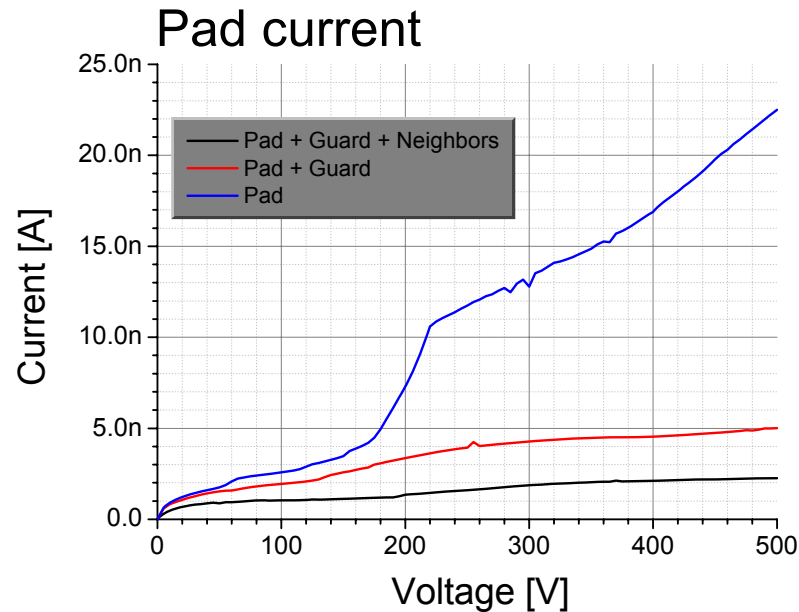
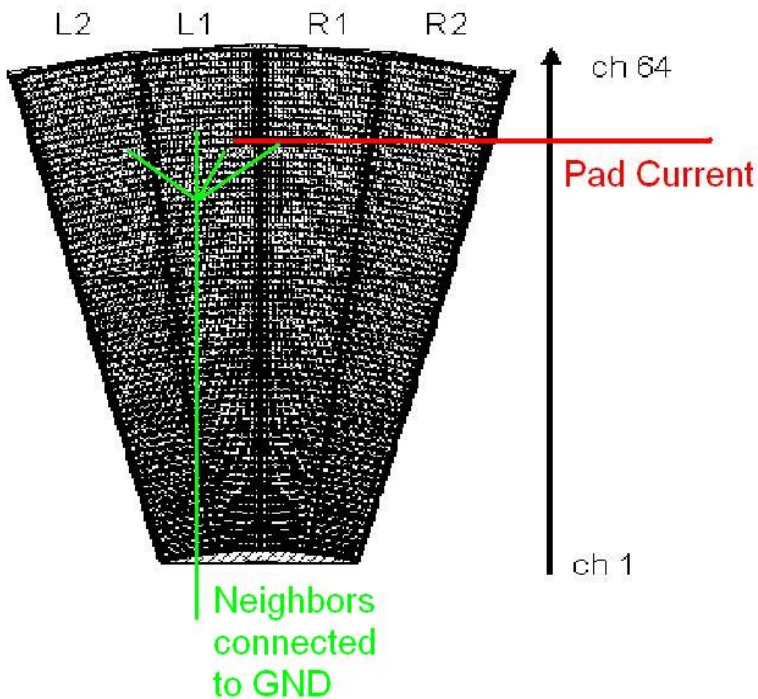


Measurement results 2



example of 1 pad with break through

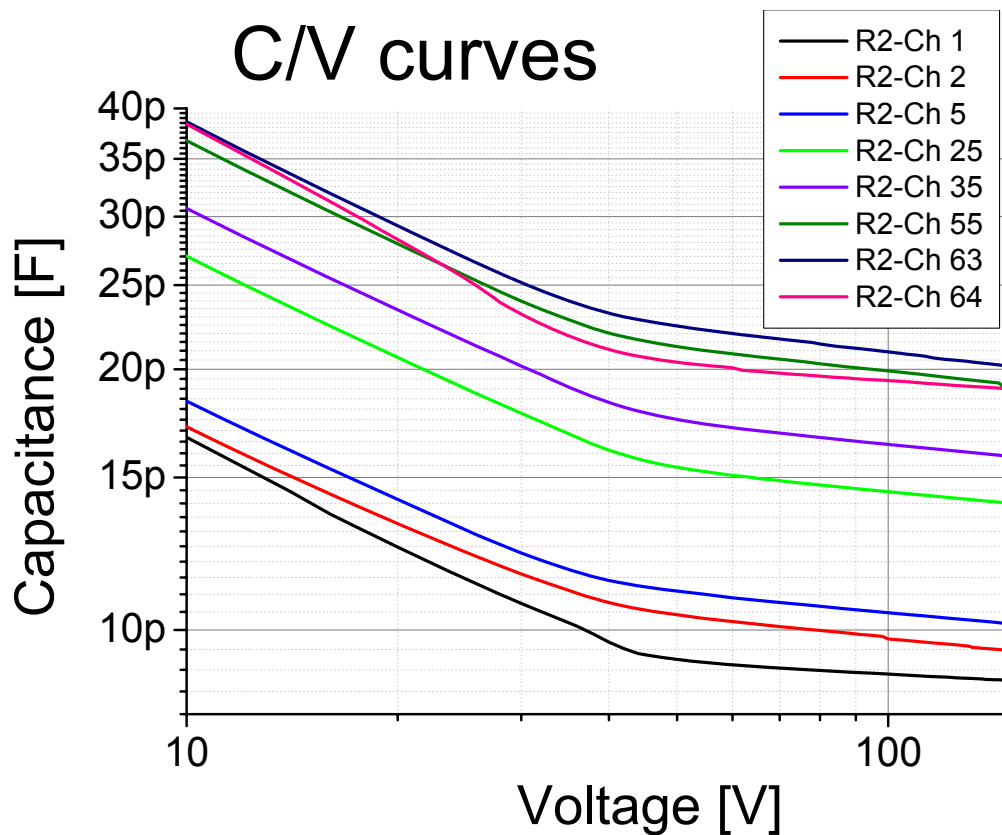
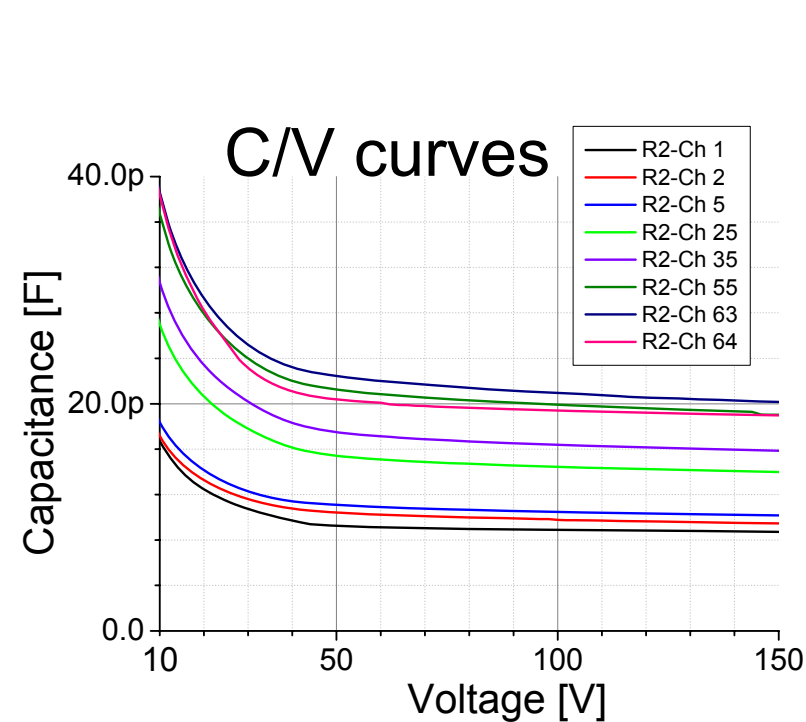
Measurement results 3



Start to study the influence of neighbors



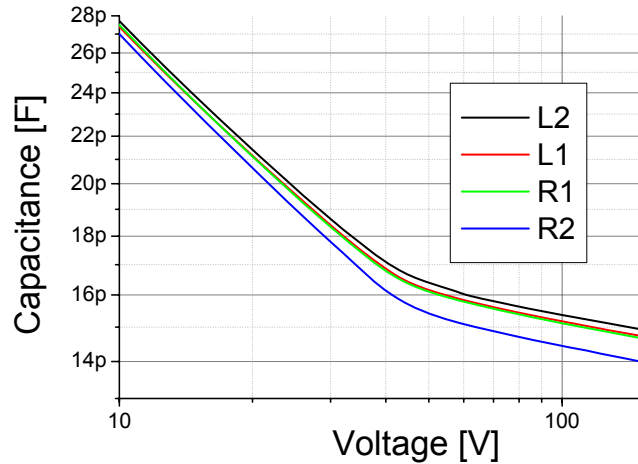
Measurement results 4



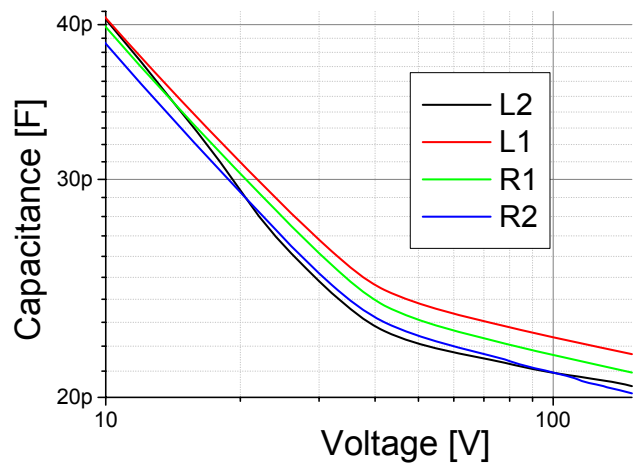
Measurement results 5



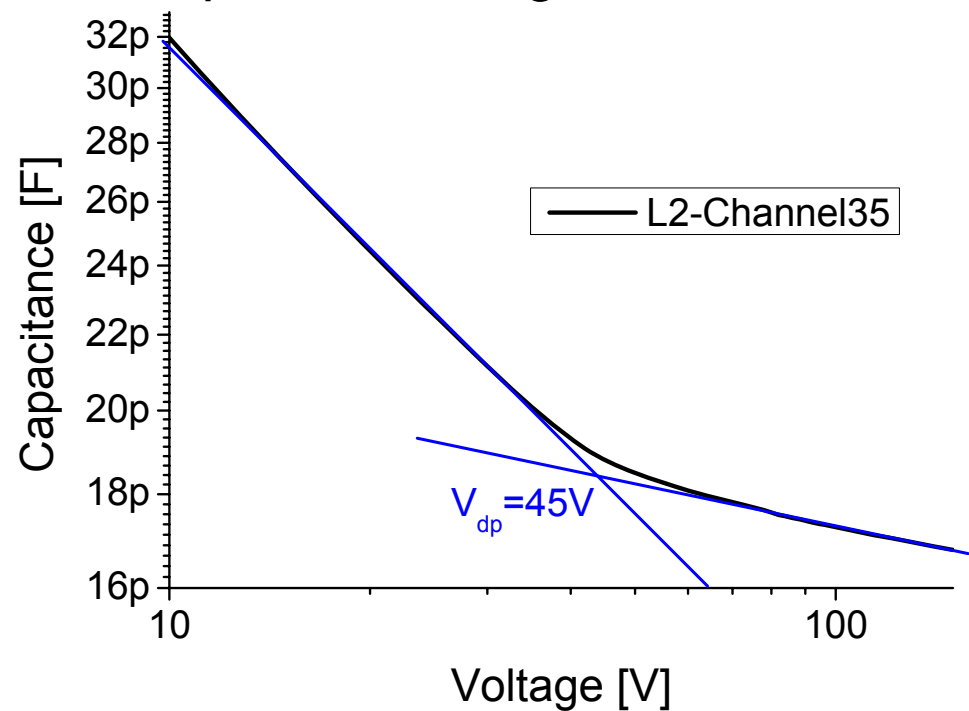
C/V of Channel 25



C/V of Channel 63



Depletion Voltage Determination



Conclusion and Outlook



- First results show that the detectors have a low leakage current ($<5\text{nA}$ @ 500V) and a depletion voltage at about 50V
- The pads are homogeneous (2 of 35 have a break through by a voltage higher than 400V)
- The measurements of all detectors will continue in July

Thank you for your attention